

PROCEEDINGS OF SPIE

Plasmonics VII

Zheyu Fang
Takuo Tanaka
Editors

14–15 October 2023
Beijing, China

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Published by
SPIE

Volume 12774

Proceedings of SPIE 0277-786X, V. 12774

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

Plasmonics VII, edited by Zheyu Fang, Takuo Tanaka,
Proc. of SPIE Vol. 12774, 1277401 · © 2023 SPIE
0277-786X · doi: 10.1117/12.3021648

Proc. of SPIE Vol. 12774 1277401-1

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Please use the following format to cite material from these proceedings:
Author(s), "Title of Paper," in *Plasmonics VII*, edited by Zheyu Fang, Takuo Tanaka, Proc. of SPIE 12774, Seven-digit Article CID Number (DD/MM/YYYY); (DOI URL).

ISSN: 0277-786X
ISSN: 1996-756X (electronic)

ISBN: 9781510667976
ISBN: 9781510667983 (electronic)

Published by
SPIE
P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone +1 360 676 3290 (Pacific Time)
SPIE.org
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